



Figure 1. (a) Structure of the laser stack. For $\text{Al}_x\text{Ga}_{(1-x)}\text{As}$ with $x=0.7$, thickness $y = 700$ nm. For $x=0.4$, thickness $y = 1400$ nm. (b) Electron channeling contrast image (ECCI) of sample with $1 \times 10^6 \text{ cm}^{-2}$ TDD. (c) TDD of $3 \times 10^7 \text{ cm}^{-2}$. (d) TDD of $4 \times 10^8 \text{ cm}^{-2}$.